

Correction

# Correction: Zhou et al. Effect of Zirconium Doping on Electrical Properties of Aluminum Oxide Dielectric Layer by Spin Coating Method with Low Temperature Preparation. *Coatings* 2020, 10, 620

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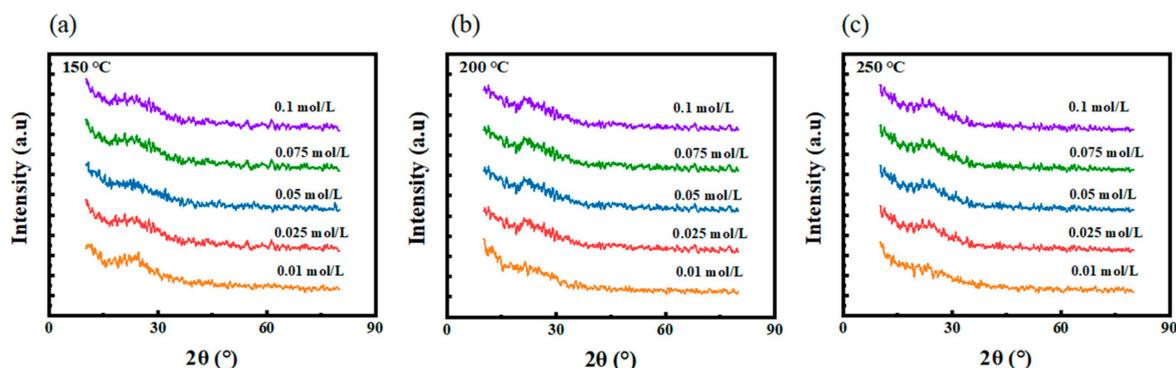
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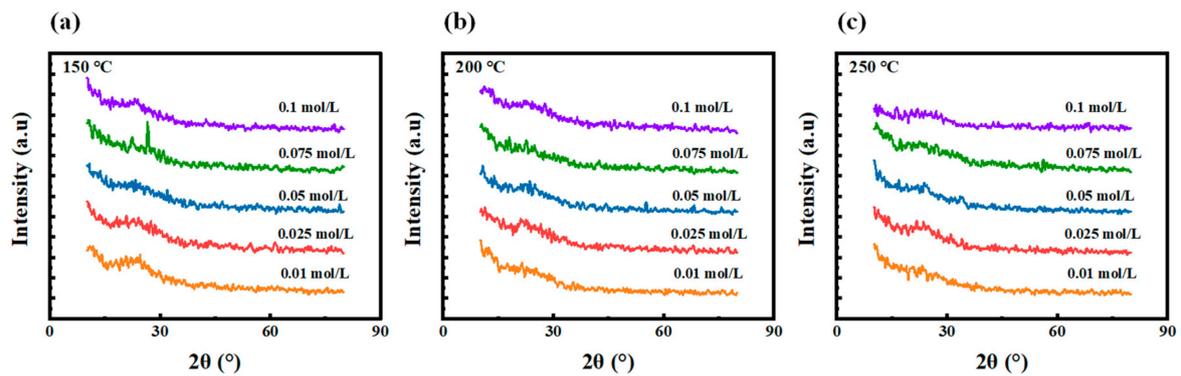
The authors wish to make the following corrections to this paper [1]:

While this manuscript was in preparation, there are some data processing errors leading to some drawing mistakes. Replace:



**Figure 2.** X-ray diffraction (XRD) spectra of Zr–AlO<sub>x</sub> films with different Zr concentrations: (a) annealing at 150 °C, (b) annealing at 200 °C, and (c) annealing at 250 °C.

with



**Figure 2.** X-ray diffraction (XRD) spectra of Zr–AlO<sub>x</sub> films with different Zr concentrations: (a) annealing at 150 °C, (b) annealing at 200 °C, and (c) annealing at 250 °C.

The authors would like to apologize for any inconvenience caused to the readers by these changes.

## Reference

1. Zhou, Y.; Liang, Z.; Yao, R.; Zuo, W.; Zhou, S.; Zhu, Z.; Wang, Y.; Qiu, T.; Ning, H.; Peng, J. Effect of Zirconium Doping on Electrical Properties of Aluminum Oxide Dielectric Layer by Spin Coating Method with Low Temperature Preparation. *Coatings* **2020**, *10*, 620. [[CrossRef](#)]

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